

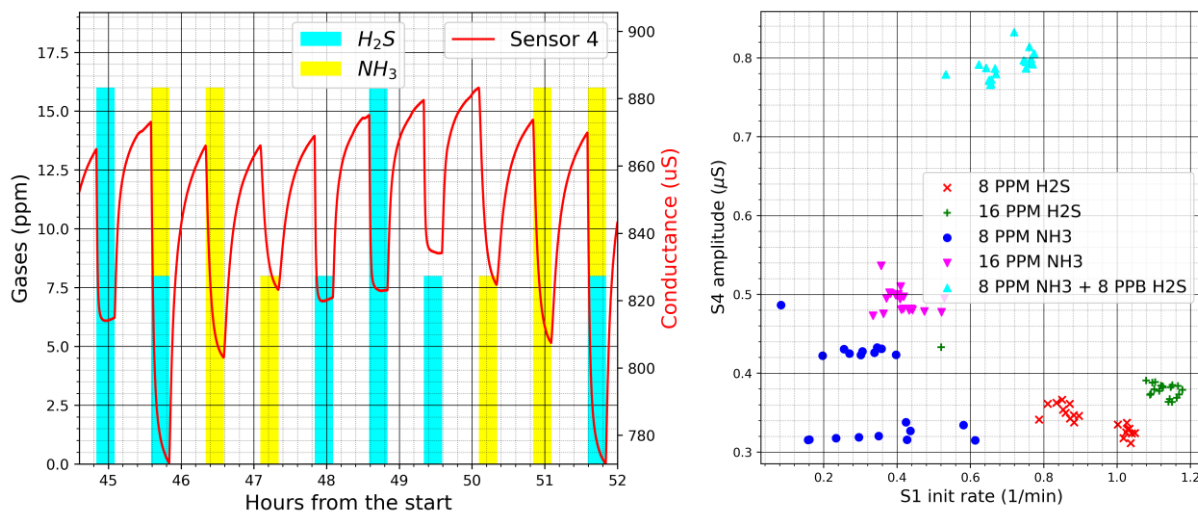
# DETECTING NH<sub>3</sub> AND H<sub>2</sub>S IN A MIXTURE IN 0-16 PPM RANGE WITH GRAPHENE-BASED GAS SENSORS

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Sensitive, miniature and low-power gas sensing elements are urgently needed for a portable electronic nose. Detecting NH<sub>3</sub> and H<sub>2</sub>S is relevant for chemical industry and agriculture<sup>1</sup>. Hereby we prepared CVD graphene-based chemiresistive sensors on SiO<sub>2</sub> / Si substrates. Graphene was functionalized with a variety of ultrathin oxide coatings by pulsed laser deposition. Over the course of several days, the heated sensors were exposed to sequentially generated cycles of 8 ppm NH<sub>3</sub>, 8 ppm H<sub>2</sub>S, 16 ppm NH<sub>3</sub>, 16 ppm H<sub>2</sub>S and 8 ppm NH<sub>3</sub> + 8 ppm H<sub>2</sub>S (left figure). Humidity was either kept constant (at 50%) or changed cyclically in sequence 20%, 40%, 60%. Various response features (amplitude, response rate, recovery rate) were considered for machine learning. The most promising features proved to be sensor amplitudes. Using artificial neural network as the classification algorithm for machine learning, we succeeded at distinguishing NH<sub>3</sub> and H<sub>2</sub>S in the relevant concentration range (right figure).



## References:

1. C. Baitong et al, 2020, *Frontiers in Environmental Science*, 8, 613646. DOI: 10.3389/fenvs.2020.613646



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